



## Gas Emissions Control and Utilization

Guest Editors:

**Dr. Zhihen Zhang**

William G. Lowrie Department of  
Chemical and Biomolecular  
Engineering, The Ohio State  
University, Columbus, OH 43210,  
USA

**Dr. Zacharias Frontistis**

Department of Chemical  
Engineering, University of  
Western Macedonia, GR-50132  
Kozani, Greece

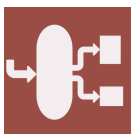
Deadline for manuscript  
submissions:  
**closed (1 December 2023)**

### Message from the Guest Editors

Gas emissions have caused severe environmental issues to human beings. Various physical, chemical, and biological technologies have been employed in efforts toward the reduction and utilization of gas pollutants. This Special Issue is partially associated with the **17th International Conference on Environmental Science and Technology (CEST2021)**. This conference will be held in Athens from 1 to 4 September 2021. The best presentations of the session "Gas Emission Control and Utilization" will be published in this Special Issue, following the normal peer review process. We are pleased to invite you to submit your work in, but not limited to, the following areas:

- Air pollution;
- Gas emission reduction (CO<sub>2</sub>, CO, SO<sub>2</sub>, H<sub>2</sub>S, NO<sub>x</sub>);
- Gas utilization and production;
- Gas storage;
- Gas capture and utilization process modeling;
- Gas emissions-related energy and environmental issues.





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## Editor-in-Chief

### Prof. Dr. Giancarlo Cravotto

Department of Drug Science and  
Technology, University of Turin,  
Via P. Giuria 9, 10125 Turin, Italy

## Message from the Editor-in-Chief

*Processes* (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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Processes Editorial Office  
MDPI, St. Alban-Anlage 66  
4052 Basel, Switzerland

Tel: +41 61 683 77 34  
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